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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	ATTORNEY DOCKET NO. CONFIRMATION NO.		
10/806,202	03/23/2004	Hiroki Yoshikawa	119162	. 1944		
25944 OLIFF & BER	7590 07/09/2007 RIDGE, PLC		EXAMINER			
P.O. BOX 1992	28		ROSASCO, STEPHEN D			
ALEXANDRIA, VA 22320			ART UNIT	PAPER NUMBER		
			1756			
			MAIL DATE	DELIVERY MODE		
	•		07/09/2007	PAPER		

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Advisory Action Before the Filing of an Appeal Brief

Application No.	Applicant(s)		
10/806,202	YOSHIKAWA ET AL.		
Examiner	Art Unit		
Stephen Rosasco	1756		

	Stephen Rosasco	1756	
The MAILING DATE of this communication appe	ars on the cover sheet with the c	orrespondence add	ress
THE REPLY FILED <u>12 June 2007</u> FAILS TO PLACE THIS APP	LICATION IN CONDITION FOR A	LLOWANCE.	
1. The reply was filed after a final rejection, but prior to or on this application, applicant must timely file one of the follow places the application in condition for allowance; (2) a No a Request for Continued Examination (RCE) in compliance time periods:	ving replies: (1) an amendment, aff tice of Appeal (with appeal fee) in o	idavit, or other evider compliance with 37 C	nce, which FR 41.31; or (3)
a) The period for reply expires <u>3</u> months from the mailing date	of the final rejection.		
b) The period for reply expires on: (1) the mailing date of this A no event, however, will the statutory period for reply expire is Examiner Note: If box 1 is checked, check either box (a) or (dvisory Action, or (2) the date set forth ater than SIX MONTHS from the mailin	g date of the final reject	on.
TWO MONTHS OF THE FINAL REJECTION. See MPEP 70		LINGI NEFLI WAS F	ILEO WITHIN
Extensions of time may be obtained under 37 CFR 1.136(a). The date have been filed is the date for purposes of determining the period of extender 37 CFR 1.17(a) is calculated from: (1) the expiration date of the set forth in (b) above, if checked. Any reply received by the Office later may reduce any earned patent term adjustment. See 37 CFR 1.704(b) NOTICE OF APPEAL	on which the petition under 37 CFR 1.1 tension and the corresponding amount shortened statutory period for reply origon than three months after the mailing da	of the fee. The approprinally set in the final Offi	iate extension fee ce action: or (2) as
 The Notice of Appeal was filed on A brief in comp filing the Notice of Appeal (37 CFR 41.37(a)), or any exter a Notice of Appeal has been filed, any reply must be filed AMENDMENTS 	nsion thereof (37 CFR 41.37(e)), to	avoid dismissal of th	ns of the date of the appeal. Since
3. The proposed amendment(s) filed after a final rejection,	hut prior to the date of filing a brief	will not be entered b	0031180
(a) They raise new issues that would require further co (b) They raise the issue of new matter (see NOTE belo	nsideration and/or search (see NO		ecause
(c) They are not deemed to place the application in bet appeal; and/or	ter form for appeal by materially re		the issues for
(d) They present additional claims without canceling a NOTE: (See 37 CFR 1.116 and 41.33(a)).	corresponding number of finally rej	ected claims.	
 The amendments are not in compliance with 37 CFR 1.13 Applicant's reply has overcome the following rejection(s) 		mpliant Amendment	(PTOL-324).
 Newly proposed or amended claim(s) would be al non-allowable claim(s). 			
7. For purposes of appeal, the proposed amendment(s): a) how the new or amended claims would be rejected is provided that the status of the claim(s) is (or will be) as follows:	☐ will not be entered, or b) ☑ will vided below or appended.	ll be entered and an e	explanation of
Claim(s) allowed:			
Claim(s) objected to:			
Claim(s) rejected: <u>1,3,5 and 7-34</u> .			
Claim(s) withdrawn from consideration: AFFIDAVIT OR OTHER EVIDENCE			
 The affidavit or other evidence filed after a final action, bu because applicant failed to provide a showing of good and 	t before or on the date of filing a No	otice of Appeal will <u>no</u> vit or other evidence is	ot be entered
was not earlier presented. See 37 CFR 1.116(e).	,		, , , , , , , , , , , , , , , , , , , ,
9. The affidavit or other evidence filed after the date of filing entered because the affidavit or other evidence failed to of showing a good and sufficient reasons why it is necessary	vercome all rejections under appea	al and/or appellant fai	ls to provide a
10. ☐ The affidavit or other evidence is entered. An explanatio REQUEST FOR RECONSIDERATION/OTHER			
11. The request for reconsideration has been considered bu	t does NOT place the application in	n condition for allowa	nce because:
12. Note the attached Information Disclosure Statement(s).	(PTO/SB/08) Paper No(s).		-
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		S. ROSASCO	

S. ROSASCO PRIMARY EXAMINER GROUP 1500 The applicant states that claims 13-24 have been seemingly ignored. While they were not listed in the heading of the rejection they are listed in the body of the rejection under 35 U.S.C. 103(a), fifth paragraph as rejected over Angelopoulos et al. (Claims 13-34), which includes instant claim 26..

The applicant argues that the formation of two or more phase shift layers on a substrate is a significant feature. The rejection under 35 U.S.C. 103(a) over Isao et al. addresses this feature, where Isao et al. teach that the phase shift film consists of at least four layers. Also there is nothing unique about the composition of these layers with respect to phase shifting as these are layers made of materials known in the art to phase shift light. The examiner maintains that adjusting the discharge powers on a sputtering target to effect a change in the composition of the deposited layers is not only shown by the prior art, but is also what one would expect if the force that produces a certain sputtered amount of material from a target is increased, that the amount of material sputtered from the target and landing on the substrate would also increase by some amount.